



Attorney's Docket No.: 006601.P086
Confirmation No.: 7571

IFW
Patent

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In Re Application of:

Cassandra M. Owen

Application No.: 10/660,646

Filed: September 12, 2003

For: ADAPTIVE THERMAL
CONTROL OF LITHOGRAPHIC
CHEMICAL PROCESSES

Examiner: Fuller, Rodney Evan

Art Unit: 2851

Mail Stop Amendment
Commissioner for Patents
P. O. Box 1450
Alexandria, VA 22313-1450

AMENDMENT AND RESPONSE TO OFFICE ACTION

Dear Sir:

In response to the Office Action dated October 5, 2004, Applicant respectfully requests that the above-identified application be amended as follows and that the following remarks be considered:

FIRST-CLASS CERTIFICATE OF MAILING

I hereby certify that this correspondence is being deposited with the United States Postal Service as first-class mail with sufficient postage in an envelope addressed to Mail Stop: Amendment, Commissioner for Patents, P. O. Box 1450, Alexandria, VA 22313-1450, on:

February 7, 2005

Date of Deposit

Esther Campbell

Name of Person Mailing Correspondence

Esther Campbell
Signature

February 7, 2005

Date

Inventor(s): Cassandra M. Owen
Application No.: 10/660,646

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